IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of: LAMARRE, Philip A. Group Art Unit: 1756

Serial No. 10/710,023 Examiner: DUDA, Kathleen

Filed: 06/14/2004 Dkt No: 20030146-US

For: LITHOGRAPHIC SEMICONDUCTOR MANUFACTURING USING A

MULTI-LAYERED PROCESS

To: Mail Stop AF From:

Commissioner for Patents

PO Box 1450

Alexandria, VA 22313-1450

Commissioner:

AFTER-FINAL OFFICE ACTION RESPONSE AMENDMENT

42716

INTRODUCTORY COMMENTS

In response to the Office's Final Office Action dated <u>9/22/06</u> the Applicant has timely enclosed herein: <u>14</u> pages Office Action Response. Please amend the above-identified application as follows:

Amendments to the Claims are reflected in the listing of claims which begins on page $\underline{2}$ of this paper.

Remarks/Arguments begin on page 6 of this paper.

[X] DEPOSIT ACCOUNT **190130** AUTHORIZATION – The Office is hereby authorized to charge the required fee, and any deficiency or credit any overpayment in the fees to the above deposit account, owned by BAE SYSTEMS Information and Electronic Systems Integration Inc. an authorized signator for which is Kevin M. Perkins, V.P. & Company Counsel, and for whom the undersigned are authorized agents.